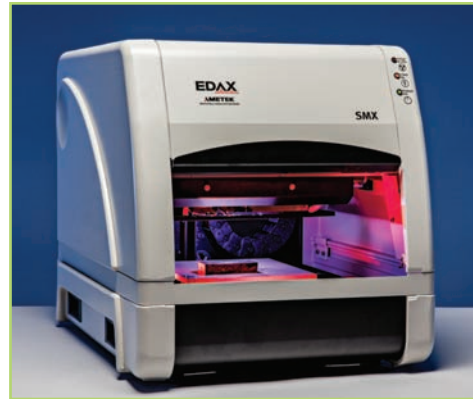


- Composition and thickness analysis by EDXRF technique
- Complete process control tool from R&D to manufacturing
- Large analysis chamber with programmable X-Y-Z stage positioning
- Versatile software for measuring film thickness and composition, solid compositional analysis, and primary metal concentrations in solution

**Application areas:**

- Manufacturing process control:  
photovoltaic, wafer level metallization, metal finishing, micro-electronics, paper, plastics
- Protective coatings:  
corrosion, wear, thermal barrier, medical implants
- Energy:  
batteries, CIGS, CIS, CdTe
- Yield management
- Failure analysis



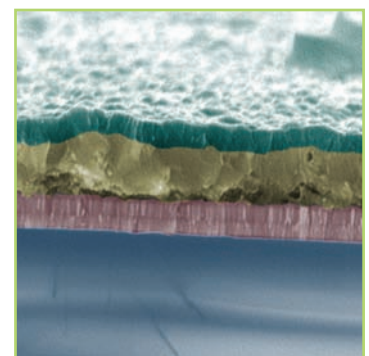
**XLNCE XRF analyzers for coating thickness and composition analysis**

The **SMX-BEN** is an XRF metrology tool that provides non-destructive analysis for composition and coating thickness measurement of single and multi-layered materials up to 30 elements, ranging from less than a nanometer to microns, quickly and accurately on virtually any substrate.

The SMX-BEN platform is an excellent choice for R&D, process development, process control, and failure analysis. It facilitates and accelerates material selection and recipe formulation in a pre- or early production ramp phase and supports in-process tool platforms well into capacity production.

SMX-BEN analyzers offer:

- An array of choices for X-ray optics and primary filters
- The latest generation of Silicon Drift Detectors (SDD)
- Optimized configuration for the fastest and most accurate results for a wide variety of applications and markets



Cross section showing CIGS layers

The analysis software platform offers both empirical and fundamental parameters (FP) options in a simple to set up calibration process. The software provides an easy-to-use interface for mastering applications from bulk sample and trace analyses to the most sophisticated multi-layer coating applications, and offers accessibility from supervisory to operator levels.

## Specifications

### X-ray tube

- 50 W, 1mA/50 kV  $\mu$ focus tube  
Targets: W, Cr (other target options available)

### Detector

- Silicon Drift Detector (SDD)

### Collimation

- 6 motorized & programmable
- Capillary option

### Primary filters

- 5 selectable & programmable

### Camera

- Constant-view variable magnification

### Optics

- 20x/40x Mag.
- 4 x 3 Field of View

### Positioning

- Motorized X-Y-Z programmable

### Focusing Laser

- Optimal Measurement  
Reproducibility

### Software

Qualitative and Quantitative Analysis, including empirical and FP Quantification options

## SMX-BEN Enhanced Features

### Primary Filters

- Allow the primary X-ray beam output to be modified for increased precision measuring specific elements.

### Laser Focusing

- Maintains precise sample-to-detector working distance for optimal measurement reproducibility.

### X-Y-Z Programmable

- Programmable positioning increases tool throughput.
- Stored X-Y-Z recipes automate repetitive testing of multiple samples.

### Quantitative Software

- Multi-layer analysis of 8 layers and up to 30 elements.
- Bulk quantitative analysis.
- Trace analysis for RoHS.

### Virtual Analysis

- Three dimensional surface mapping for visual inspection of fine sample structures.

### Statistical Tool

- Histogram, Trendline, X-Bar, and R-Chart display along with Mean, Std. Deviation, %Dev, Pp/Ppk, and Min/Max data charts.

